

Open access • Journal Article • DOI:10.1039/C7TA06119F

Ultrathin petal-like NiAl layered double oxide/sulfide composites as an advanced electrode for high-performance asymmetric supercapacitors — Source link

Lei Li, Kwan San Hui, Kwun Nam Hui, Young-Rae Cho

Institutions: Pusan National University, University of East Anglia, University of Macau

Published on: 26 Sep 2017 - Journal of Materials Chemistry (The Royal Society of Chemistry)

Topics: Nial and Capacitance

Related papers:

- 3D porous layered double hydroxides grown on graphene as advanced electrochemical pseudocapacitor materials
- OD to 3D carbon-based networks combined with pseudocapacitive electrode material for high energy density supercapacitor: A review
- · A review of electrode materials for electrochemical supercapacitors
- Facile synthesis of NiAl layered double hydroxide nanoplates for high-performance asymmetric supercapacitor
- Hierarchical ultrathin NiAl layered double hydroxide nanosheet arrays on carbon nanotube paper as advanced hybrid electrode for high performance hybrid capacitors

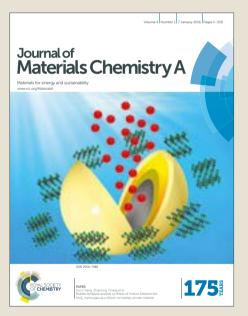


View Article Online View Journal

Journal of Materials Chemistry A

Accepted Manuscript

This article can be cited before page numbers have been issued, to do this please use: L. Li, K.S. Hui, K. N. Hui and Y. R. Cho, *J. Mater. Chem. A*, 2017, DOI: 10.1039/C7TA06119F.



This is an Accepted Manuscript, which has been through the Royal Society of Chemistry peer review process and has been accepted for publication.

Accepted Manuscripts are published online shortly after acceptance, before technical editing, formatting and proof reading. Using this free service, authors can make their results available to the community, in citable form, before we publish the edited article. We will replace this Accepted Manuscript with the edited and formatted Advance Article as soon as it is available.

You can find more information about Accepted Manuscripts in the **author guidelines**.

Please note that technical editing may introduce minor changes to the text and/or graphics, which may alter content. The journal's standard <u>Terms & Conditions</u> and the ethical guidelines, outlined in our <u>author and reviewer resource centre</u>, still apply. In no event shall the Royal Society of Chemistry be held responsible for any errors or omissions in this Accepted Manuscript or any consequences arising from the use of any information it contains.



rsc.li/materials-a

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35.

1	Ultrathin Petal-like NiAl Layered Double Oxide/Sulfide Composites as Advanced
2]	Electrode for High-performance Asymmetric Supercapacitor
3	
4]	Lei Li ^a , Kwan San Hui ^{b*} , Kwun Nam Hui ^{c*} , and Young Rae Cho ^{a*}
5	
6	
7 ⁸	^a School of Materials Science and Engineering, Pusan National University, San 30 Jangjeon-
8 (dong, Geumjeong-gu, Busan 609-735, Republic of Korea
9 ^t	^b School of Mathematics, University of East Anglia, Norwich, NR4 7TJ, United Kingdom
10 0	^c Institute of Applied Physics and Materials Engineering, University of Macau, Avenida da
11	Universidade, Macau, China
12	
13	
14 *	*Corresponding author:
15	E-mail: k.hui@uea.ac.uk (Kwan San Hui)
16	E-mail: bizhui@umac.mo (Kwun Nam Hui)
17	E-mail: yescho@pusan.ac.kr (Young Rae Cho)
18	
19	
20	
21	
22	
23	

1 Abstract

2 Layered double hydroxide (LDH) is an important layer-structured material for 3 supercapacitors because of its versatile compositions, high theoretical capacitance, environmental friendliness, and low cost. However, the high resistivity of this material results 4 5 in capacity fading, limiting its application in energy storage. Herein, we develop a facile approach to synthesize ultrathin petal-like NiAl layered double oxide/sulfide (LDO/LDS) 6 composites with high electrochemical activity using hydrothermal reaction followed by 7 sulfidation process. Scanning electron micrograph shows that the petal-like NiAl LDO/LDS 8 composites are as thin as ~ 10 nm with a mean lateral dimension of ~ 1 µm. The NiAl 9 LDO/LDS electrode delivers remarkably high specific capacitance of 2250.5 F g^{-1} at 1 A g^{-1} 10 compared with that of NiAl LDH (1740.5 F g^{-1} at 1 A g^{-1}) and possesses good cycling ability 11 of 88.9% capacitance retention over 5000 cycles at 5 A g^{-1} . Asymmetric supercapacitor (ASC) 12 is fabricated using NiAl LDO/LDS and graphene as positive and negative electrodes, 13 respectively. NiAl LDO/LDS//G ASC exhibits specific capacitance of 153.3 F g^{-1} at 1 A g^{-1} , 14 high energy density of 47.9 Wh kg⁻¹ at a power density of 750 W kg⁻¹, and reliable cycling 15 stability of 95.68% capacitance retention after 5000 cycles. Results highlight that NiAl 16 LDO/LDS composites are promising materials for energy storage devices with long cycling 17 stability. 18

19

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

KEYWORDS: layered double oxide/sulfide; nanoplate; ultrathin; asymmetric supercapacitor;
 sulfidation

- 22
- 23
- 24

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

1

2

1. Introduction

Supercapacitors have electric double-layer capacitors generally composed of carbonaceous 3 materials based on electrostatic adsorption/desorption. Pseudocapacitors utilizing transition 4 5 metal oxides/hydroxides based on Faradaic reactions are advantageous because of their high power density, fast charge propagation dynamics, and long cycle life compared with 6 batteries.¹⁻⁴ Among transitional metal oxides, layered double hydroxide (LDH) consisting of 7 brucite-like host layers and charge-compensating interlayer anions has attracted significant 8 attention as promising electrode materials in electrochemistry because of their high redox 9 activity, relatively low cost, and environmental friendliness.⁵⁻⁸ The general formula of LDHs 10 can be described as $[M_{1-x}^{2+}M_x^{3+}(OH)_2](A^{n-})_{x/n} \cdot mH_2O$, where M^{2+} indicates the divalent 11 cation (Ni²⁺, Co²⁺, Cu²⁺, Zn²⁺, Mg²⁺, etc.), M³⁺ indicates the trivalent cation (Al³⁺, Mn³⁺, Cr³⁺, 12 Fe³⁺, etc.), and Aⁿ⁻ indicates the interlayer exchangeable anion (OH-, SO⁴⁻, NO³⁻, etc.).^{9,10} 13 14 Based on the layered structure, electrical double-layer capacitance can be obtained by the 15 abundant slabs in the structure, while Faradaic reactions can be achieved at the surface of the electroactive sites for charge storage.^{5, 8} Therefore, LDH materials hold the great potential for 16 achieving high energy density and power density simultaneously compared with other 17 supercapacitive electrode materials.^{8, 11, 12} However, the high electrical resistivity of LDH 18 adversely affects the electron transfer kinetics, resulting in poor cycling stability. This 19 characteristic impedes the potential of LDH in commercial applications.^{5, 13-15} 20

21

22 Morphology engineering is an effective approach to improve the electrochemical 23 performance of electrode materials. For example, ultrathin mesoporous nanostructures, such 24 as NiO,^{16, 17} Co₃O₄,¹⁸ and NiCo₂O₄¹⁹, have been reported to demonstrate high specific

capacitance, high-rate capability, and excellent cycling performance in energy storage 1 2 applications, because huge electroactive sites on the exposed surface are available for electrochemical reaction with electrolyte ions.²⁰ Meanwhile, sulfidation to convert low 3 electrical conductive metal oxide to high electrical conductive metal sulfide has been reported. 4 Electrochemical performance of electrode materials is enhanced because of the higher 5 electrical conductivity of sulfide-based oxides.^{21, 22} Pu et al. reported NiCo₂S₄ nanotubes 6 arrays on Ni foam exhibiting high specific capacitance of 738 F g^{-1} at 4 A g^{-1} with excellent 7 rate capability of 78% capacitance retention at 32 A g^{-1} and good cycling stability showing 8 retention capacity of 93.4 % after 4000 cycles.²³ Hou et al. reported Ni₇S₆/Co₃O₄ nanoboxes 9 with intriguing pseudocapacitance that delivered a remarkable specific capacitance of 677 F 10 g^{-1} at 4 A g^{-1} .²⁴ However, electrochemical properties of sulfide-based NiAl-LDH are rarely 11 reported. Herein, we report a facile approach to synthesize NiAl layered double oxide/sulfide 12 composites (LDO/LDS) with high electrochemical activity using hydrothermal reaction 13 14 followed by sulfidation process. For comparison, electrochemical performance of NiAl LDH 15 synthesized without sulfidation was also compared. The NiAl LDO/LDS electrode delivers remarkably high specific capacitance of 2250.5 F g^{-1} at 1 A g^{-1} compared with that of NiAl 16 LDH (1740.5 F g^{-1} at 1 A g^{-1}) and possesses good cycling ability of 88.9% capacitance 17 retention over 5000 cycles at 5 A g⁻¹. An asymmetric supercapacitor (ASC) was fabricated 18 using NiAl LDO/LDS and graphene as positive and negative electrodes, respectively. NiAl 19 LDO/LDS//G ASC exhibits specific capacitance of 153.3 F g^{-1} at 1 A g^{-1} , high energy density 20 of 47.9 Wh kg⁻¹ at a power density of 750 W kg⁻¹, and reliable cycling stability of 95.68% 21 capacitance retention after 5000 cycles. Hence, the petal-like NiAl LDO/LDS composites 22 23 may serve as a promising electrode material for many potential applications such as photocatalysts, electrocatalysts, batteries because of its excellent physical and chemical 24

properties.25,26 1

2

2. Experimental details 3

4 2.1 Synthesis of petal-like NiAl LDH nanosheets

5 Nickel nitrate hexahydrate $(Ni(NO_3)_2 \cdot 6H_2O),$ aluminum nitrate nonahydrate $(Al(NO_3)_3 \cdot 9H_2O)$, sodium thiosulfate $(Na_2S_2O_3)$, and urea $((NH_2)_2CO)$ were purchased from 6 7 Sigma Aldrich (USA). Acetone and anhydrous ethanol were purchased from SK Chemical 8 (South Korea). All chemicals were of analytical grade and used without further purification. The petal-like NiAl LDH nanosheets were synthesized using a simple hydrothermal 9 method.²⁴ Ni(NO₃)₂·6H₂O (0.003 mol) and Al(NO₃)₃·9H₂O (0.001 mol) were dissolved in 10 11 30 mL of deionized (DI) water with vigorous stirring for 15 min. Subsequently, urea (0.015 mol) was added into the mixture and stirred for another 15 min. Then, the solution was 12 transferred to a 50 mL Teflon-lined autoclave and kept at 120 °C for 12 h. After cooling 13 14 down to room temperature, the as-synthesized product was taken and rinsed using DI water 15 and ethanol, followed by drying at 80 °C for 12 h.

16

24

17 2.2. Preparation of petal-like NiAl LDO/LDS composites

NiAl LDO/LDS was prepared by mixing as-prepared NiAl LDH powder with $Na_2S_2O_3$ at a 18 19 mole ratio of 1:2, and the mixture was manually ground for 30 min in an agate mortar. 20 Subsequently, the mixed powder was transferred in a quartz tube and heated in high-purity argon gas atmosphere at 400, 500, 600, and 700 °C for 12 h. After cooling down to room 21 22 temperature, the black color NiAl LDO/LDS composites were washed several times with ethanol to prevent the hydrolysis of Al_2S_3 to $Al(OH)_3$ and H_2S and drying at 80 °C for 12 h. 23

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

1 **2.3.** Preparation of graphene

2 Graphite oxide was prepared using natural graphite (Asbury Carbons) through the modified Hummers method as reported elsewhere.^{27, 28} Similar to a typical experiment, graphite flakes 3 (3.0 g) were stirred in concentrated sulfuric acid (70 mL) at room temperature, followed by 4 5 the addition of sodium nitrate (1.5 g). Potassium permanganate (9.0 g) was added slowly to keep the solution temperature lower than 20 °C while maintaining the reaction flask in an ice 6 bath. The entire reaction system was subsequently placed into a 35 °C water bath for 30 min, 7 8 and slurry was formed. Afterward, 140 mL of DI water was added to the slurry, and the suspension was stirred for another 15 min. The solution was diluted with additional DI water 9 (500 mL) and treated with 20 mL of H₂O₂ (30 wt%) until no gas was produced. The solution 10 11 color changed from brown into yellow. The mixture was filtered and washed with 1:10 HCl aqueous solution (250 mL) to provide the graphene oxide solution. Graphene was obtained by 12 a hydrothermal reaction of the graphene oxide solution (2 mg mL⁻¹, 40 mL) in a 50 mL 13 Teflon-lined autoclave and kept at 180 °C for 10 h. The product was cleaned with ethanol and 14 15 water and freeze-dried overnight.

16

17 2.4. Material characterization

18 X-ray diffraction (XRD) patterns were recorded using a Bruker D8 Advanced X-Ray 19 Diffractometer with Ni-filtered Cu K α radiation ($\lambda = 1.5406$ Å) at voltage of 40 kV and 20 current of 200 mA. The composition and valence states of the prepared samples were 21 analyzed by X-ray photoelectron spectroscopy (XPS, VG Scientifics ESCALAB250), and the 22 instrument was calibrated to the carbon peak C 1s at 284.6 eV. Field-emission scanning 23 electron microscopy (FESEM) images were acquired using Hitachi S–4800. Transmission 24 electron microscopy (TEM) images were obtained using Talos F200 X. Scanning

- Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35.
- 1 transmission electron microscopy with energy dispersive X-ray spectroscopy (EDS) (Talos
- 2 F200 X) mapping was performed to identify the distributions of Ni, Al, O, and S.
- 3

4 2.5. Electrochemical measurements

5 Electrochemical measurements were conducted in a three-electrode electrochemical system containing 6 M KOH as electrolyte at room temperature. The active material on nickel foam 6 $(1 \text{ cm} \times 1 \text{ cm})$ was selected as the working electrode. Platinum foil and a saturated calomel 7 8 electrode (SCE) were used as the counter and reference electrodes, respectively. Cyclic voltammetry (CV) and galvanostatic charge/discharge (GCD) were performed on an Ivium-n-9 Stat electrochemical workstation (Ivium, Netherlands). Electrochemical impedance spectrum 10 (EIS) measurements were conducted in the frequency range of 100 kHz to 0.1 Hz in the open 11 12 circuit potential with alternating current perturbation of 5 mV.

13

14 Fabrication of the NiAl LDO/LDS//G ASC

15 The ASCs were packaged in a CR 2302 coin cell. In this cell, NiAl LDO/LDS electrode, 16 graphene electrode, cellulose fabric, and 6 M KOH solution were used as the positive 17 electrode, negative electrode, separator, and electrolyte, respectively. The positive and negative electrodes were prepared as follows. The prepared active materials, acetylene black, 18 19 and polytetrafluoroethylene in mass proportion of 75:20:5 were mixed by adding a small amount of ethanol to produce a homogeneous mash. The mass loadings of the NiAl LDO/LD 20 S and graphene samples were determined to be 1.5 and 7.5 mg, respectively. Then, the 21 22 resulting slurry was coated onto a nickel foam current collector. Finally, the fabricated electrode was pressed and dried at 80 °C overnight and was then cut into a round film. The 23 24 mass loading ratio of NiAl LDO/LDS to graphene was balanced to be approximately 0.20 to

(3)

Journal of Materials Chemistry A Accepted Manuscript

$$C_{device} = \frac{I \times \Delta t}{\Delta V \times M} \tag{1}$$

$$\mathbf{E} = \frac{1}{2} C_{device} \Delta V^2 \tag{2}$$

$$P = \frac{E}{\Delta t}$$

7 where *I* is the discharge current (*A*), Δt is the discharge time (*s*), *M* is the electrode 8 mass (*g*), and ΔV is the operating potential window of the device (*V*).

9

4

5

6

10 **3. Results and discussion**

11 **3.1. Material characterization**

12 Fig. 1a shows the XRD pattern of the NiAl LDH. Well-defined main diffraction peaks are displayed at 11.7°, 23.5°, 35.1°, 39.7°, 47.3°, 61.2°, 62.5°, and 66.5° which can be indexed as 13 the (003), (006), (012), (015), (018), (110), (113), and (116) crystal planes of NiAl LDH 14 (JCPDS 15-0087).^{30, 31} Fig. 1b shows the XRD spectra of the as-obtained NiAl LDO/LDS 15 16 composites contained at sulfidation temperature of 500 °C, which are indexed to the 17 diffraction planes of Ni₃S₂ (JCPDS 44-1418), NiO (JCPDS 01-1239), and Al₂S₃ (JCPDS 47-1313).^{32, 33} This result confirms the successful conversion of NiAl LDH to NiAl LDO/LDS. 18 Scheme 1 displayed the sulfidation of NiAl LDH occurs during the thermal annealing process 19 20 with sulfide source. Meanwhile, the XRD patterns and the corresponding SEM images of the 21 NiAl LDO/LDS composites obtained at various sulfidation temperature (400, 600, and 22 700 °C) were shown in Fig. S1. When the sulfidation temperature increases, the crystallinity 23 of the NiAl LDO/LDS composites increases, signifying by the increasing intensity of the (110) peaks of the Ni₃S₂ phase (Fig. S1a). At sulfidation temperature of 700 °C, the NiO 24

peaks disappear, and the pure NiAl LDS is formed. However, the morphology of the NiAl LDO/LDS composites degrades at 600 °C (Fig. S1c) and aggregates to form a particle-like morphology when the sulfidation temperature reaches 700 °C (Fig. S1d). Hence, the NiAl LDO/LDS composites obtained at sulfidation temperature of 500 °C exhibits intact petal-like morphology and desirable LDS characteristics, which is selected as the optimized NiAl LDO/LDS composites in this study. The hierarchical petal-like NiAl LDO/LDS LDO/LDS Composites are formed according to the following reactions.^{34, 35}

8 Decomposition process

9

$Ni(OH)_2 \rightarrow NiO + H_2O \tag{4}$

$$10 \qquad \qquad 2\text{Al}(\text{OH})_3 \rightarrow \text{Al}_2\text{O}_3 + 3\text{H}_2\text{O} \tag{5}$$

$$4Na_2S_2O_3 \rightarrow 3Na_2SO_4 + Na_2S_5 \tag{6}$$

12 Synthetic process

13
$$3NiO + \frac{3}{4}Na_2S_5 \rightarrow Ni_3S_2 + \frac{3}{4}Na_2SO_4 + \frac{1}{2}S_2$$
 (7)

14
$$Al_2O_3 + Na_2S_5 \rightarrow Al_2S_3 + \frac{1}{4}Na_2S + \frac{3}{4}Na_2SO_4 + \frac{1}{2}S_2$$
 (8)

15

XPS was used to evaluate the surface chemical states of NiAl LDO/LDS composites. Fig. 2a 16 17 clearly reveals that the composites are composed of Ni, Al, S, and O elements. Furthermore, the element composition (at.%) of the NiAl LDO/LDS composites is depicted in Table S1. 18 The results clearly show that the existence of the S (5.06 at.%) in the NiAl LDO/LDS 19 20 composites. The high-resolution X-ray photoelectron spectrum of Ni 2p is shown in Fig. 2b. 21 Two spin-orbit doublets (shown at 856.1 eV and 873.9 eV) with their shakeup satellites 22 (indicated by "Sat") correspond to Ni $2p_{3/2}$ and Ni $2p_{1/2}$, and this result confirms the presence of Ni^{2+,35} The Al 2p X-ray photoelectron spectrum (Fig. 2c) is observed at 74.2 eV, 23 suggesting the existence of Al^{3+,36} The O 1s peaks (Fig. S2) with the binding energies of 24

529.8 eV and 531.2 eV corresponds to the metal oxygen bonds and oxygen ions, respectively.
After sulfidation process, NiAl LDO/LDS composites exhibits S 2p_{3/2} and S 2p_{1/2}, which are
shown as a strong peak at 162.3 eV and a smaller peak at 163.5 eV, respectively.^{37, 38} The
results clearly indicate the existence of metal-sulfur bonds in the NiAl LDO/LDS composites.

Scanning electron micrographs were used to investigate the surface morphology of NiAl 6 LDH and NiAl LDO/LDS composites (Fig. 3). After the hydrothermal process, 3D 7 8 hierarchical architecture composed of interconnected petal-like NiAl LDH nanosheets are formed (Fig. 3a and b). Ultrathin NiAl LDH nanosheets with a mean thickness of 10 nm and 9 width of $\sim 1 \, \mu m$ are achieved. Such unique feature of LDH nanosheets can effectively 10 promote ion diffusion and charge transport. After sulfidation, the color of the LDH changes 11 from light green to black. Interestingly, NiAl LDO/LDS composites maintain the same 12 morphology but become more porous and dense (Figs. 3c and d). This phenomenon 13 14 illustrates that sulfidation not only retains the structural advantages of NiAl LDH but also 15 results in higher degree of hierarchical structure, which is beneficial to electrochemical 16 performance.

17

5

The microstructure of the NiAl LDO/LDS composites was further investigated by TEM. As shown in Figs. 4a and b, the transmission electron micrographs indicate a specifically crosslinked structure of NiAl LDO/LDS composites consisting of many ultrathin nanosheets. In addition, TEM and AFM measurements were used as the effective means to evaluate the thickness of the NiAl LDO/LDS composites. As shown in Fig. S3a, TEM image reveals that the thicknesses of the petal-like NiAl LDO/LDS composites are approximately 8 to 10 nm. A single piece of the NiAl LDO/LDS composites was prepared by dispersing the sample

10

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

powder in ethanol with sonication for 2 h prior to AFM test. The results show that the 1 2 thickness of the NiAl LDO/LDS sheet is approximately 7.09 nm (Fig. S3bc). The selectedarea electron diffraction (SAED) pattern (inset in Fig. 4b) exhibits well-defined diffraction 3 rings which are attributed to the (110) planes of Ni₃S₂ phases. This finding is consistent with 4 5 the XRD data. Hence, these results indicate the polycrystalline nature of the NiAl LDO/LDS composites. Clear lattice fringes (Fig. 4c) show an equal interplanar distance of 0.28 nm and 6 0.23 nm corresponding to the (110) plane of Ni_3S_2 and (111) plane of NiO. To further 7 confirm the spatial distribution of chemical components, EDS mapping (Fig. 4d) shows a 8 homogeneous distribution of Ni, Al, S, and O in the NiAl LDO/LDS composites. 9

The electrochemical properties of the NiAl LDH and NiAl LDO/LDS electrodes were 11 evaluated using a three-electrode test. According to the NiAl LDH synthesis reaction:³⁹ 12

13
$$6Ni^{2+} + 2Al^{3+} + 16OH^{-} + CO_3^{2-} + 4H_2O \rightarrow Ni_6Al_2(OH)_{16}CO_3 \cdot 4H_2O$$
 (9)

Al is used to supporting the structure and does not participate in the Faradaic reactions.^{40,41} 14 15 The theoretical specific capacitance of NiAl LDH is contributed from Ni(OH)₂, which has a theoretical specific capacitance of 2082 F g⁻¹.⁴² Fig. 5a presents the CV curves of the NiAl 16 LDH and NiAl LDO/LDS electrodes at a scan rate of 5 mVs⁻¹ in the voltage range of 0 V to 17 0.6 V (vs. SCE). Two pairs of distinct redox peaks were detected in CV curves, indicating the 18 typical pseudocapacitive nature of the electrodes. The reversible redox reactions of nickel are 19 suggested as follows: ^{38, 43} 20

Faradaic redox reaction in NiAl LDH electrode 21

22

24

 $Ni(OH)_2 + OH^- \leftrightarrow NiOOH + H_2O + e^-$ (10)

Faradaic redox reaction in NiAl LDO/LDS electrode 23

$$Ni_3S_2 + 30H^- \leftrightarrow Ni_3S_2(0H)_3 + 3e^-$$
(11)

2 Fig. 5a shows that the NiAl LDO/LDS electrode exhibits a larger integral area and higher current density compared with the NiAl LDH electrode. These characteristics suggest the 3 improved specific capacitance caused by the improved conductivity and fast ion transport. 4 Figs. 5b and c exhibit the CV measurement of NiAl LDH and NiAl LDO/LDS electrodes at 5 various scan rates (5, 10, 20, 30, 40, 50, and 100 mV s^{-1}), respectively. The results indicate 6 that the redox peaks present small shift and without obvious shape change with increasing 7 scan rates. These characteristics signify the high reversibility of the electrode materials.^{44, 45} 8 The cathodic peak current was correlated against the square root of the scan rate (Fig. 5d). 9 The NiAl LDO/LDS electrode evidently shows higher linear relationship than the NiAl LDH 10 electrode with increasing $v^{1/2}$, and this phenomenon is attributed to the rapid electrolyte 11 diffusion in the electrode.⁴⁶ The diffusion coefficients of NiAl LDO/LDS and NiAl LDH 12 electrodes were further elucidated by investigating the ion diffusion kinetics property of the 13 electrodes using the following Randles-Sevcik equation: ^{24, 32} 14

15

1

$$i_p = (2.69 \times 10^5) n^{3/2} A D_o^{1/2} Co^* v^{1/2}$$
(12)

where i_p is the peak current of the electrode, *n* is the electron transfer number, *A* is the electrode area, D_o is the diffusion coefficient, C_o^* is the reactant concentration, and *v* is the scan rate.

$$D_{\rm LDO/LDS}/D_{\rm LDH} = \left[(i_p/v^{1/2})_{\rm LDO}/_{\rm LDS}/(i_p/v^{1/2})_{\rm LDH} \right]^2$$
(13)

The results show that the diffusion coefficient of NiAl LDO/LDS electrode is 2.2 times higher compared with that of the NiAl LDH electrode. Thus, the ultrathin petal-like NiAl LDO/LDS composites are more favorable to ion diffusion, and this characteristic further improves the electrochemical performance of the electrode.

24

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

1

2

Fig. 6a shows the GCD measurements of the NiAl LDH and NiAl LDO/LDS electrodes with

the potential window from 0 V to 0.4 V at a current density of 1 A g^{-1} . The different current

View Article Online DOI: 10.1039/C7TA06119F

densities of the electrodes are shown in Figs. 6b and c. In this case, the nonlinear discharge 3 curves reveal the pseudocapacitance behavior attributed to the electrochemical quasi-4 reversible redox reactions at the electrolyte-electrode interface.⁵ The NiAl LDO/LDS 5 electrode displays longer discharge time, indicating higher specific capacitance. The specific 6 capacitances of NiAl LDH and NiAl LDO/LDS electrodes at different current densities are 7 demonstrated in Fig. 6d. The specific capacitance values of the NiAl LDH electrode at 8 current densities of 1, 3, 5, 8, and 10 A g^{-1} are found to be 1740.5, 1567.5, 1497.5, 1432.3, 9 and 1400.4 F g⁻¹, respectively. Similarly, the specific capacitance values of the NiAl 10 LDO/LDS electrode are 2250.5, 1567.5, 2170.5, 2047.6, 1936.7, and 1880.8 F g^{-1} , 11 respectively. NiAl LDO/LDS electrode exhibits a higher specific capacitance compared with 12 NiAl LDH at the tested current density. In addition, the NiAl LDO/LDS electrode exhibits 13 14 higher specific capacitance compared previously reported electrode materials in literature 15 (Table S3). This phenomenon is ascribed to the increased effective active sites after sulfidation.24 16

17

Fig. 7a shows the cycling performance of NiAl LDH and NiAl LDO/LDS electrodes at different current densities. At the beginning of the first 100 cycles, the NiAl LDO/LDS electrode displays a prominent specific capacitance of 2250.5 F g⁻¹ at 1 A g^{-1} , which is higher than that of the NiAl LDH electrode (1740.5 F g⁻¹ at 1 A g⁻¹). The specific capacitance gradually decreases with increasing current densities. This phenomenon is ascribed to the polarization effect of the electrode during fast charging/discharging.^{47, 48} At low current density, abundant electrolyte ions are

supplied to the electrode material active sites, leading to higher specific capacitance. 1 2 However, at high current density, the effective interaction between the electrode materials and electrolyte ions is remarkably reduced.⁴⁹ The capacitance retention of 3 NiAl LDO/LDS electrode is 97% (2180.5 F g⁻¹), which is higher than that of NiAl 4 LDH electrode (96%, 1672 F g⁻¹). The electrochemical life of the NiAl LDO/LDS 5 electrode was further investigated by performing GCD cycling measurement at the 6 current density of 5 A g^{-1} for 5000 cycles. The result indicates an excellent retention at 7 88.9% (specific capacitance of 1820.25 F g^{-1}) after 5000 cycles, which is better than 8 the NiAl LDH electrode at 83.8% (specific capacitance of 1458.54 F g^{-1}). Meanwhile, 9 the value sharply decreases at the first 300 cycles, and this reduction might be 10 attributed to the materials of the NiAl LDO/LDS electrode which tend to stabilize after 11 activation. This superior cycling performance might be due to several factors. First, 12 the special cross-linked and porous structure shortens the diffusion path which 13 14 ascertains the rapidly ion diffusion kinetics. Second, sulfidation transforms the metal oxide to metal sulfide species Ni₃S₂, which supplies additional electrochemical active 15 sites for Faradic redox reaction.⁵⁰ Finally, the sulfidation increases the internal 16 conductivity of electrode materials which enhances the electrochemical stability.⁵¹ 17 Moreover, the NiAl LDO/LDS electrode remains the Coulombic efficiency of 94.1% 18 at a current density of 5 A g^{-1} during 5000 charge-discharge cycles, which is higher 19 than that of the NiAl LDH electrode (88.2%) (Fig. S4). 20

21

EIS analysis was further performed to measure the internal resistances and charge transfer kinetics of the electrode for SCs.⁵² Fig. 7c shows the EIS curves and fitted results of the NiAl LDH and NiAl LDO/LDS electrodes based on the equivalent circuit depicted in the inset of

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

Fig. 7c. The equivalent circuit was used to measure the impedance properties of the 1 2 electrodes. These properties include the internal resistance (R_s) , Faradic charge transfer 3 resistance ($R_{\rm cl}$), Warburg diffusion element ($Z_{\rm w}$), double layer capacitance ($C_{\rm dl}$), and pseudocapacitance $(C_{\rm F})$.^{36, 53, 54} Originally, the Nyquist plots displays a semicircle in the highfrequency region which can be attributed to charge transfer process between the electrode materials and electrolyte. Subsequently, a sloped line is observed in the low-frequency region, and this result suggests the electrolyte ion diffusion in the electrode materials.⁵⁵ According to the result, the intercept on the real impedance z' axis at the high-frequency region represents the internal resistance (R_s) , which includes the intrinsic resistance of the electrode materials, resistance of KOH electrolyte, and the contact resistance at the active electrode material and nickel foam interface.⁵ The NiAl LDO/LDS electrode shows a smaller semicircle and a steeper slope compared with the NiAl LDH electrode. The impedance result of the two electrodes was obtained from the complex nonlinear least square fitting as shown in Table S2. The results show that the NiAl LDO/LDS electrode exhibits lower internal resistance (0.499 Ω) and charge transfer resistance (0.308 Ω) than the NiAl LDH electrode (0.665 Ω and 12.53 Ω).

17

Fig. 8a presents the CV curves of graphene and NiAl LDO/LDS composites electrodes at the scan rate of 5 mV s⁻¹. The graphene electrode displays a typical rectangular curve at the voltage range from -1 V to 0 V, whereas NiAl LDO/LDS composites electrode exhibits a pseudocapacitive characteristic at the voltage range from 0 V to 0.6 V. These characteristics result in a wide potential window of 1.6 V. CV curves of NiAl LDO/LDS//G ASC display similar non-rectangular capacitive behavior at various scan rates of 5, 10, 20, 30, 50 and 100 mV s⁻¹ between 0 V and 1.6 V (Fig. 8b), suggesting good electrochemical reversibility and

high rate capability of the ASC. The CV curves in Fig. 8b show a non-rectangular capacitive 1 2 behavior. This is because the potential window of the NiAl LDO/LDS//G ASC is composed of electric double layer capacitance and Faradaic redox behaviors, which agrees well with 3 similar reports.^{8, 56} The GCD curves of NiAl LDO/LDS//G ASC (Fig. 8c.) depict small 4 voltage loss (IR drop) in the device, revealing a low internal resistance of the ASC device. 5 Fig. 8d shows the specific capacitance of the NiAl LDO/LDS//G ASC delivering high 6 specific capacitances of 153.3, 82.8, 70.67, 61.87, and 60 F g^{-1} at 1, 3, 5, 8, and 10 A g^{-1} , 7 respectively. The NiAl LDO/LDS//G ASC retains 95.68% of its initial specific capacitance at 8 5 A g^{-1} after 5000 charge-discharge cycles (Fig. 8e), indicating good electrochemical stability. 9 In addition, the Coulombic efficiency of the device remains at 86.7%, indicating an excellent 10 reversibility.^{57, 58} Fig. 8f displays the Ragone plot of NiAl LDO/LDS//G ASC with high 11 energy density of 47.9 Wh kg⁻¹ at a power density of 750 W kg⁻¹. This impressive energy 12 density is obviously larger than those of other reported ASC devices, such as NiAl 13 LDH/GNS//GNS (31.5 Wh kg⁻¹ at 400 W kg⁻¹),⁵⁹ NiO//CNTs (27.8 Wh kg⁻¹ at 700 W 14 kg^{-1}),⁶⁰ NiO//C (19 Wh kg^{-1} at 32 W kg^{-1}),⁶¹ Ni(OH)₂ (36.2 Wh kg^{-1} at 100.6 W kg^{-1}),⁶² 15 Ni(OH)₂@3D Ni//AC (21.8 Wh kg⁻¹ at 660 W kg⁻¹),⁶³ and NiCo LDH//AC (23.7 Wh kg⁻¹ at 16 248 W kg⁻¹).⁶⁴ 17

18

19 Conclusions

In conclusion, petal-like porous NiAl LDO/LDS composites material has been fabricated through a facile hydrothermal method followed by sulfidation process. The as-fabricated NiAl LDO/LDS electrode exhibits excellent supercapacitor performance with specific capacitance of 2250.5 F g⁻¹ at 1 A g⁻¹ and remarkable cycling stability compared with NiAl LDH electrode (1740.5 F g⁻¹ at 1 A g⁻¹). The ultrathin nanoplate morphology and sulfide content account for the impressive electrochemical performance. Finally, the NiAl

LDO/LDS//G ASC device delivers high energy density of 47.9 Wh kg⁻¹ at a power density of

750 W kg⁻¹ with exceptional cycling stability of 95.68% cell capacitance retention after 5000 Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35 cycles. This work highlights a simple sulfidation approach to synthesize sulfidized LDH material with high cycling stability for high-performance supercapacitors. Acknowledgements This work was supported by the Science and Technology Development Fund from Macau SAR (FDCT-098/2015/A3), the UEA funding, and the Basic Science Research Program through the National Research Foundation (NRF) funded by Korea Ministry of Education (2016R1D1A1B02009234).

1		
2		
3		
4		
5		
6		
7		
8		
9	Refer	rences
10	1.	C. Yuan, H. B. Wu, Y. Xie and X. W. D. Lou, Angew. Chem. Int. Ed., 2014, 53, 1488.
11	2.	J. Yang, C. Yu, X. Fan and J. Qiu, Adv. Energy Mater., 2014, 4, 1400761.
12	3.	M. Winter and R. J. Brodd, Chem. Rev., 2004, 104, 4245-4269.
13	4.	J. R. Miller and P. Simon, <i>Science</i> , 2008, 321 , 651-652.
14	5.	L. J. Zhang, J. Wang, J. J. Zhu, X. G. Zhang, K. S. Hui and K. N. Hui, J. Mater. Chem.
15		<i>A</i> , 2013, 1 , 9046-9053.
16	6.	Z. Li, M. Shao, L. Zhou, R. Zhang, C. Zhang, J. Han, M. Wei, D. G. Evans and X.
17		Duan, Nano Energy, 2016, 20, 294-304.
18	7.	L. Zhang, K. N. Hui, K. S. Hui and H. Lee, <i>Electrochim. Acta</i> , 2015, 186, 522-529.
19	8.	H. Lai, Q. Wu, J. Zhao, L. Shang, H. Li, R. Che, Z. Lyu, J. Xiong, L. Yang and X.
20		Wang, Energy Environ. Sci., 2016, 9, 2053-2060.
21	9.	M. F. Shao, R. K. Zhang, Z. H. Li, M. Wei, D. G. Evans and X. Duan, Chem.
22		Commun., 2015, 51 , 15880-15893.
23	10.	J. Xu, F. He, S. L. Gai, S. H. Zhang, L. Li and P. P. Yang, Nanoscale, 2014, 6, 10887-
24		10895.

11.	L. Zhang, K. N. Hui, K. S. Hui and H. Lee, <i>Electrochim. Acta</i> , 2015, 186, 522-529.
12.	F. Ning, M. Shao, C. Zhang, S. Xu, M. Wei and X. Duan, Nano Energy, 2014, 7, 134-
	142.
13.	L. Yan, R. Li, Z. Li, J. Liu, Y. Fang, G. Wang and Z. Gu, Electrochim. Acta, 2013, 95,
	146-154.
14.	L. J. Zhang, X. G. Zhang, L. F. Shen, B. Gao, L. Hao, X. J. Lu, F. Zhang, B. Ding and
	C. Z. Yuan, J. Power Sources, 2012, 199, 395-401.
15.	J. P. Cheng, J. H. Fang, M. Li, W. F. Zhang, F. Liu and X. B. Zhang, Electrochim.
	Acta, 2013, 114 , 68-75.
16.	G. H. Cheng, W. F. Yang, C. Q. Dong, T. Y. Kou, Q. G. Bai, H. Wang and Z. H. Zhang,
	J. Mater. Chem. A, 2015, 3 , 17469-17478.
17.	S. X. Wu, K. S. Hui, K. N. Hui and K. H. Kim, J. Mater. Chem. A, 2016, 4, 9113-9123.
18.	Q. Yang, Z. Y. Lu, X. M. Sun and J. F. Liu, Sci. Rep., 2013, 3, 3537.
19.	C. Z. Yuan, J. Y. Li, L. R. Hou, X. G. Zhang, L. F. Shen and X. W. Lou, Adv. Funct.
	Mater., 2012, 22, 4592-4597.
20.	Y. Q. Zhu, C. B. Cao, S. Tao, W. S. Chu, Z. Y. Wu and Y. D. Li, Sci. Rep., 2014, 4,
	5787.
21.	X. Y. Yu, L. Yu, L. F. Shen, X. H. Song, H. Y. Chen and X. W. Lou, Adv. Funct. Mater.,
	2014, 24 , 7440-7446.
22.	Y. M. Chen, Z. Li and X. W. Lou, Angew. Chem. Int. Ed., 2015, 54, 10521-10524.
23.	J. Pu, T. T. Wang, H. Y. Wang, Y. Tong, C. C. Lu, W. Kong and Z. H. Wang,
	Chempluschem, 2014, 79 , 577-583.
24.	H. Hua, S. J. Liu, Z. Y. Chen, R. Q. Bao, Y. Y. Shi, L. R. Hou, G. Pang, K. N. Hui, X.
	G. Zhang and C. Z. Yuan, Sci. Rep., 2016, 6, 20973.
	19
	 12. 13. 14. 15. 16. 17. 18. 19. 20. 21. 22. 23.

- L. Lu, H.-y. Wang, J.-G. Wang, C. Wang and Q.-C. Jiang, J. Mater. Chem. A, 2017, 5,
 2530-2538.
- 3 26. J. Hong, Y.-W. Lee, D. Ahn, S. Pak, J. Lee, A.-R. Jang, S. Lee, B. Hou, Y. Cho and S.
 4 M. Morris, *Nano Energy*, 2017, **39**, 337-345.
- 5 27. R. O. WILLIAMS . HUMMERS JR., J. Am. Chem. Soc., 1958, 80, 1339.

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

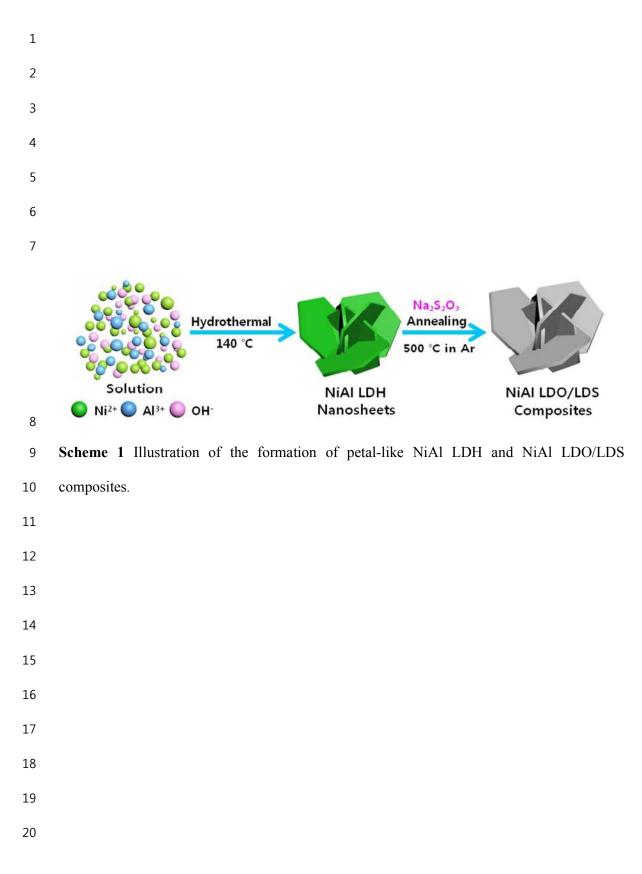
- 8 28. N. I. Kovtyukhova, P. J. Ollivier, B. R. Martin, T. E. Mallouk, S. A. Chizhik, E. V.
 7 Buzaneva and A. D. Gorchinskiy, *Chem. Mater.*, 1999, 11, 771-778.
- 8 29. H. Liang, C. Xia, Q. Jiang, A. N. Gandi, U. Schwingenschlögl and H. N. Alshareef,
 9 *Nano Energy*, 2017, 35, 331-340.
- 10 30. L. J. Zhang, K. N. Hui, K. S. Hui, X. Chen, R. Chen and H. W. Lee, *Int. J. Hydrogen Energy*, 2016, **41**, 9443-9453.
- 12 31. L. Li, K. San Hui, K. N. Hui, Q. Xia, J. Fu and Y.-R. Cho, *J. Alloys Compd.*, 2017,
 13 721, 803-812.
- 14 32. Q. X. Xia, K. S. Hui, K. N. Hui, S. D. Kim, J. H. Lim, S. Y. Choi, L. J. Zhang, R. S.
 15 Mane, J. M. Yun and K. H. Kim, *J. Mater. Chem. A*, 2015, **3**, 22102-22117.
- 16 33. L. W. Mi, Q. Ding, W. H. Chen, Z. Zheng, H. W. Hou, C. T. Liu and C. Y. Shen, *RSC*17 *Adv.*, 2012, **2**, 6817-6823.
- 34. S. J. Peng, L. L. Li, H. T. Tan, R. Cai, W. H. Shi, C. C. Li, S. G. Mhaisalkar, M.
 Srinivasan, S. Ramakrishna and Q. Y. Yan, *Adv. Funct. Mater.*, 2014, 24, 2155-2162.
- 20 35. H. Pang, C. Z. Wei, X. X. Li, G. C. Li, Y. H. Ma, S. J. Li, J. Chen and J. S. Zhang, *Sci.*21 *Rep.*, 2014, 4, 3577.
- 36. J. Memon, J. H. Sun, D. L. Meng, W. Z. Ouyang, M. A. Memon, Y. Huang, S. K. Yan
 and J. X. Geng, *J. Mater. Chem. A*, 2014, 2, 5060-5067.
- 24 37. Y. J. Ruan, J. J. Jiang, H. Z. Wan, X. Ji, L. Miao, L. Peng, B. Zhang, L. Lv and J. Liu,

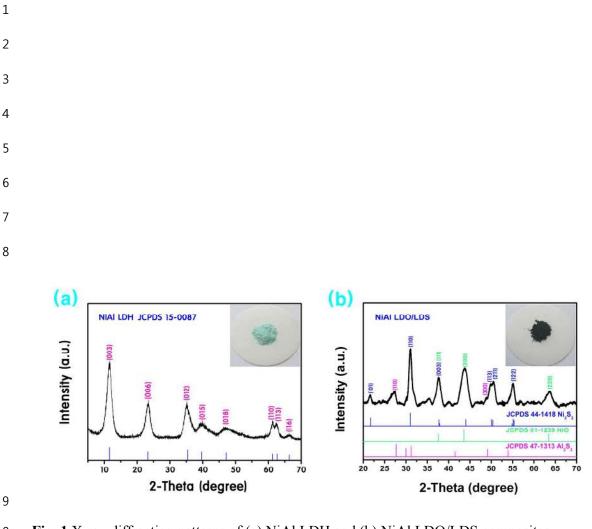
1		<i>J. Power Sources</i> , 2016, 301 , 122-130.
2	38.	Z. Zhang, Q. Wang, C. Zhao, S. Min and X. Qian, ACS Appl. Mater. Inter., 2015, 7,
3		4861-4868.
4	39.	S. X. Wu, K. S. Hui and K. N. Hui, J. Phys. Chem. C, 2015, 119, 23358-23365.
5	40.	D. Du, X. Wu, S. Li, Y. Zhang, W. Xing, L. Li, Q. Xue, P. Bai and Z. Yan, J. Mater.
6		Chem. A, 2017, 5 , 8964-8971.
7	41.	L. Zhang, R. Chen, K. N. Hui, K. San Hui and H. Lee, Chem. Eng. J., 2017, 325, 554-
8		563.
9	42.	J. Yan, Z. J. Fan, W. Sun, G. Q. Ning, T. Wei, Q. Zhang, R. F. Zhang, L. J. Zhi and F.
10		Wei, Adv. Funct. Mater., 2012, 22, 2632-2641.
11	.43.	J. C. Xing, Y. L. Zhu, Q. W. Zhou, X. D. Zheng and Q. J. Jiao, Electrochim. Acta,
12		2014, 136 , 550-556.
13	44.	K. Karthikeyan, S. Amaresh, V. Aravindan, H. Kim, K. S. Kang and Y. S. Lee, J.
14		Mater. Chem. A, 2013, 1, 707-714.
15	45.	Y. Zhao, X. Zhang, J. He, L. Zhang, M. Xia and F. Gao, <i>Electrochim. Acta</i> , 2015, 174,
16		51-56.
17	46.	B. Liu, H. T. Yuan, Y. S. Zhang, Z. X. Zhou and D. Y. Song, J. Power Sources, 1999,
18		79 , 277-280.
19	47.	H. Ma, J. He, DB. Xiong, J. Wu, Q. Li, V. Dravid and Y. Zhao, ACS Appl. Mater.
20		Inter., 2016, 8, 1992-2000.
21	48.	Y. Zhao, H. Ma, S. Huang, X. Zhang, M. Xia, Y. Tang and ZF. Ma, ACS Appl. Mater.
22		Inter., 2016, 8, 22997-23005.
23	49.	K. B. Xu, R. J. Zou, W. Y. Li, Q. Liu, X. J. Liu, L. An and J. Q. Hu, J. Mater. Chem. A,
24		2014, 2 , 10090-10097.

1	50.	Y. Lu, B. Jiang, L. Fang, F. Ling, F. Wu, B. Hu, F. Meng, K. Niu, F. Lin and H. Zheng,
2		J. Alloys Compd., 2017, 714, 63-70.
3	51.	B. Yang, L. Yu, Q. Liu, J. Liu, W. Yang, H. Zhang, F. Wang, S. Hu, Y. Yuan and J.
4		Wang, CrystEngComm, 2015, 17, 4495-4501.
5	52.	Y. F. Xu, M. G. Schwab, A. J. Strudwick, I. Hennig, X. L. Feng, Z. S. Wu and K.
6		Mullen, Adv. Energy Mater., 2013, 3, 1035-1040.
7	53.	X. Wang, C. Y. Yan, A. Sumboja and P. S. Lee, <i>Nano Energy</i> , 2014, 3 , 119-126.
8	54.	B. Wang, Q. Liu, Z. Y. Qian, X. F. Zhang, J. Wang, Z. S. Li, H. J. Yan, Z. Gao, F. B.
9		Zhao and L. H. Liu, J. Power Sources, 2014, 246, 747-753.
10	55.	F. L. Lai, Y. E. Miao, Y. P. Huang, T. S. Chung and T. X. Liu, J. Phys. Chem. C, 2015,
11		119 , 13442-13450.
12	56.	X. Ren, C. Guo, L. Xu, T. Li, L. Hou and Y. Wei, ACS Appl. Mater. Inter., 2015, 7,
13		19930-19940.
14	57.	J. Lin, Y. Liu, Y. Wang, H. Jia, S. Chen, J. Qi, C. Qu, J. Cao, W. Fei and J. Feng, J.
15		<i>Power Sources</i> , 2017, 362 , 64-72.
16	58.	B. Wei, H. Liang, D. Zhang, Z. Wu, Z. Qi and Z. Wang, J Mater Chem A, 2017, 5,
17		2844-2851.
18	59.	L. J. Zhang, K. N. Hui, K. S. Hui, X. Chen, R. Chen and H. Lee, Int. J. Hydrogen
19		Energy, 2016, 41 , 13329-13329.
20	60.	H. W. Wang, H. Yi, X. Chen and X. F. Wang, <i>Electrochim. Acta</i> , 2013, 105 , 353-361.
21	61.	D. W. Wang, F. Li and H. M. Cheng, J. Power Sources, 2008, 185, 1563-1568.
22	62.	J. C. Huang, P. P. Xu, D. X. Cao, X. B. Zhou, S. N. Yang, Y. J. Li and G. L. Wang, J.
23		<i>Power Sources</i> , 2014, 246 , 371-376.
24	63.	Y. Z. Su, K. Xiao, N. Li, Z. Q. Liu and S. Z. Qiao, J. Mater. Chem. A, 2014, 2, 13845-
		22

1	13853.
2	64. X. Wang, A. Sumboja, M. F. Lin, J. Yan and P. S. Lee, <i>Nanoscale</i> , 2012, 4 , 7266-7272.
3	
4	
5	
6	
7	
8	
9	
10	Scheme 1 Illustration of the formation of petal-like NiAl LDH and NiAl LDO/LDS
11	composites.
12	Fig. 1 X-ray diffraction patterns of (a) NiAl LDH and (b) NiAl LDO/LDS composites.
13	Fig. 2 X-ray photoelectron spectra of NiAl LDO/LDS composites: (a) full spectrum, (b) Ni
14	2p, (c) Al 2p, and (d) S 2p.
15	Fig. 3 Field-emission scanning electron micrographs of the (a, b) NiAl LDH and (c, d) NiAl
16	LDO/LDS composites.
17	Fig. 4 (a, b) Transmission electron micrographs (inset in b) the corresponding SAED pattern,
18	and (c) high-resolution transmission electron micrograph and (d) Energy dispersive X-ray
19	spectral mapping of the NiAl LDO/LDS composites.
20	Fig. 5 Cyclic voltammograms of (a) NiAl LDO/LDS and NiAl LDH electrodes at the scan
21	rate of 5 mV s^{-1} and (b) NiAl LDH electrode and (c) NiAl LDO/LDS electrode at different
22	scan rates. (d) Linear relationship between the cathodic peak current and square root of the
23	scan rate.
24	Fig. 6 Galvanic change-discharge curves of (a) NiAl LDO/LDS and NiAl LDH at a current

density of 1 A g⁻¹, and (b) NiAl LDH electrode and (c) NiAl LDO/LDS electrode at different 1 2 current densities. (d) Specific capacitances of NiAl LDH and NiAl LDO/LDS electrodes at 3 different current densities. Fig. 7 Cycling performances of (a) NiAl LDO/LDS and NiAl LDH electrodes at different 4 current densities and (b) the petal-like NiAl LDO/LDS composites at a current density of 5 A 5 g^{-1} . (c) Nyquist plots of the NiAl LDO/LDS and NiAl LDH electrodes. 6 Fig. 8 Cyclic voltammograms of (a) graphene and NiAl LDO/LDS at a scan rate of 5 mV s⁻¹ 7 and (b) NiAl LDO/LDS//G ASC device at different scan rate. (c) GCD curves of NiAl 8 LDO/LDS//G ASC device at different current densities, (d) Specific capacitances of NiAl 9 LDO/LDS//G ASC device at different current densities. (e) Cycling performance and 10 Coulombic efficiency of LDO/LDS//G ASC device at 5 A g⁻¹. (f) Ragone plot of NiAl 11 LDO/LDS//G ASC device. 12 13 14 15 16 17 18 19 20 21 22 23 24









Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

Journal of Materials Chemistry A

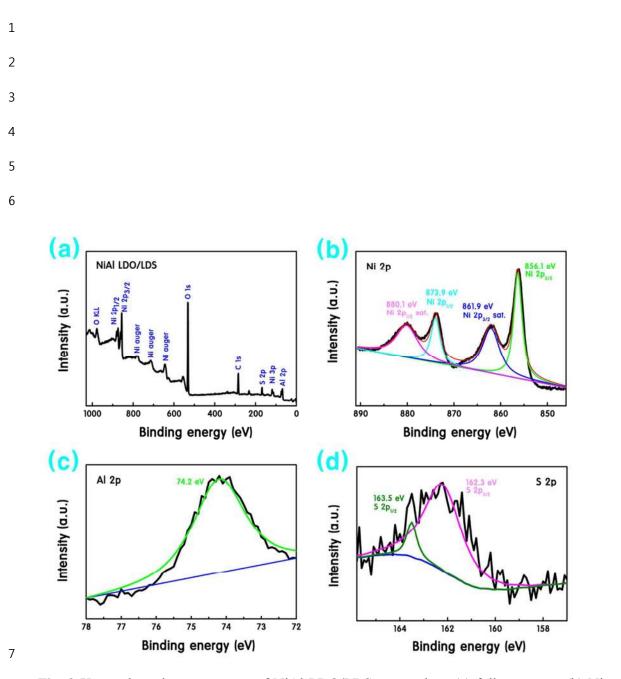
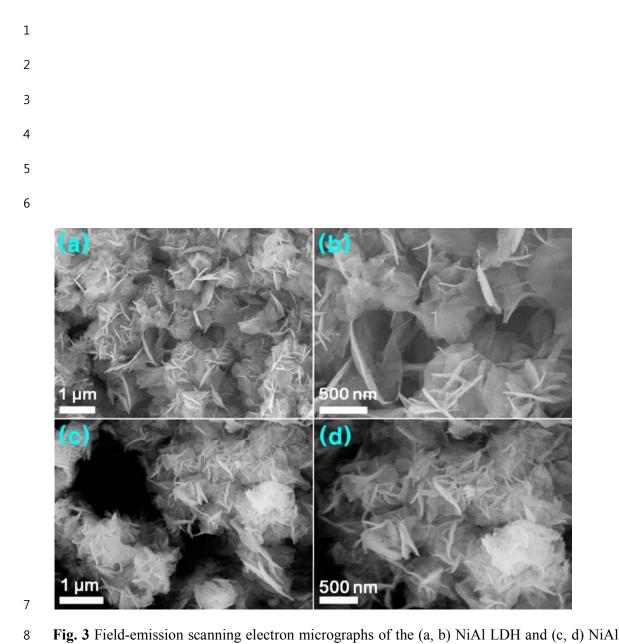


Fig. 2 X-ray photoelectron spectra of NiAl LDO/LDS composites: (a) full spectrum, (b) Ni
2p, (c) Al 2p, and (d) S 2p.

10

- 11
- 12



LDO/LDS composites.

10

9

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35.

- 11
- 12
- 13
- 12
- 14

28

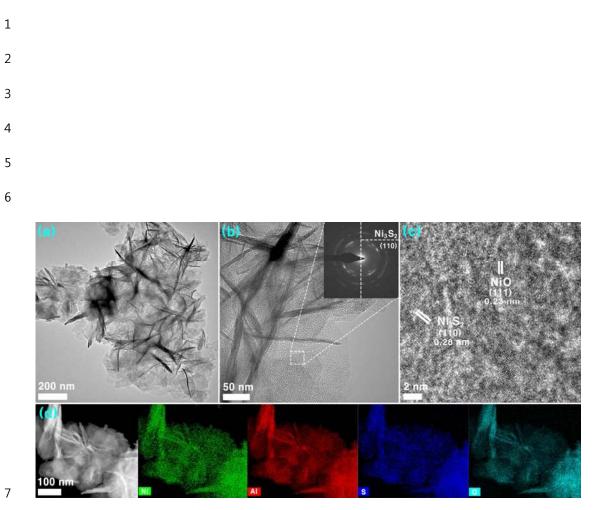


Fig. 4 (a, b) Transmission electron micrographs (inset in b) the corresponding SAED pattern,
and (c) high-resolution transmission electron micrograph and (d) Energy dispersive X-ray
spectral mapping of the NiAl LDO/LDS composites.

11

12

13

14

15

16

17



Journal of Materials Chemistry A Accepted Manuscript

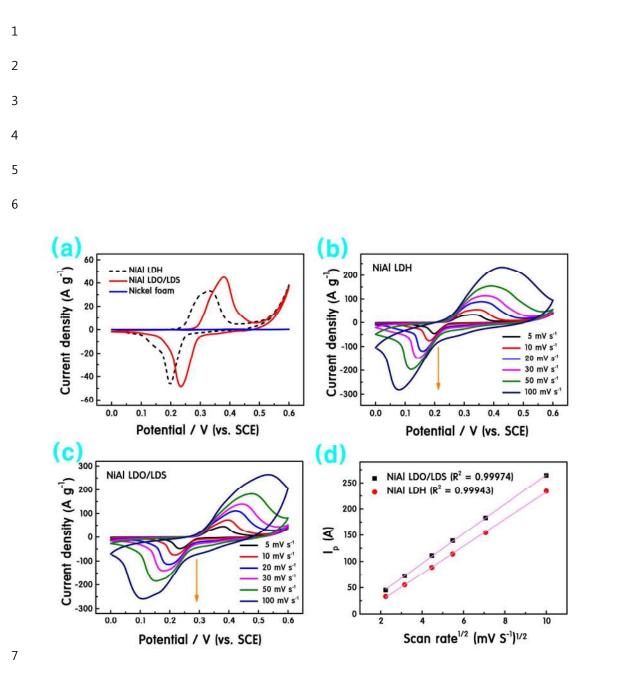


Fig. 5 Cyclic voltammograms of (a) NiAl LDO/LDS and NiAl LDH electrodes at the scan
rate of 5 mV·s⁻¹ and (b) NiAl LDH electrode and (c) NiAl LDO/LDS electrode at different
scan rates. (d) Linear relationship between the cathodic peak current and square root of the
scan rate

12

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

Journal of Materials Chemistry A

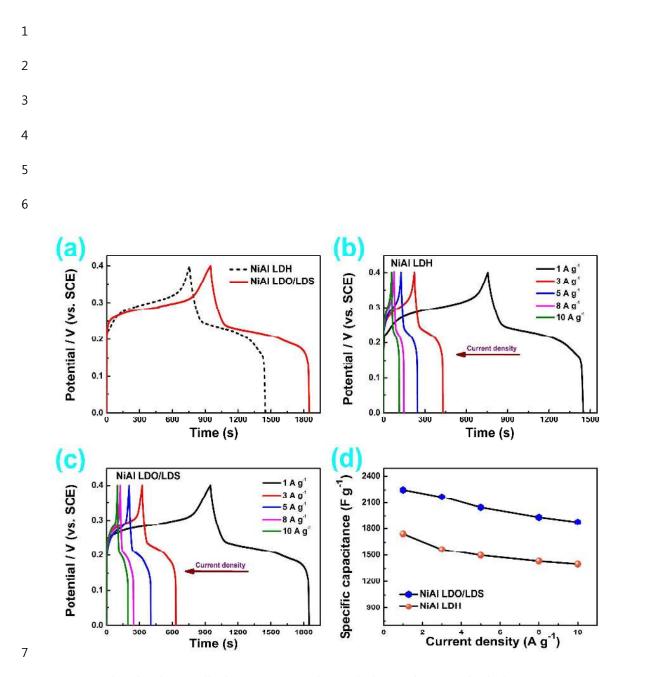
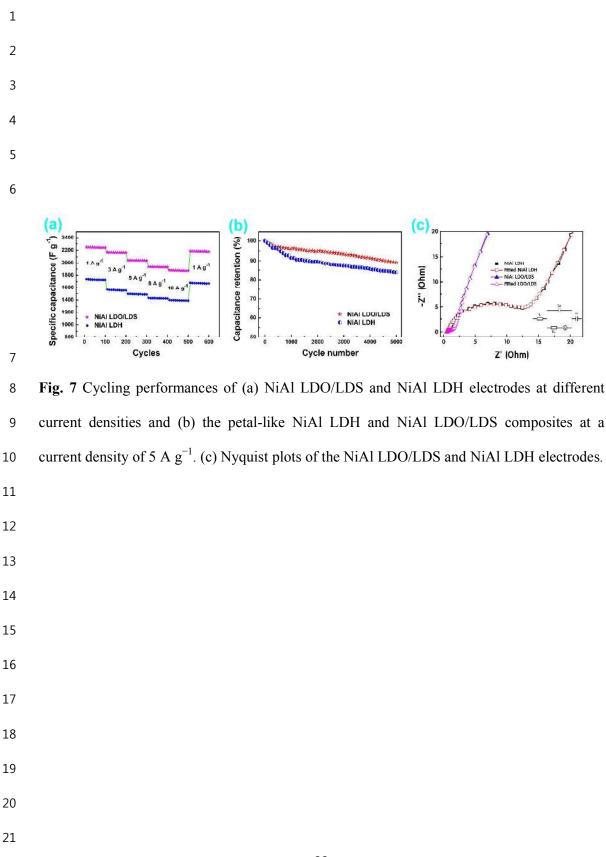


Fig. 6 Galvanic change-discharge curves of (a) NiAl LDO/LDS and NiAl LDH at a current
density of 1 A g⁻¹, and (b) NiAl LDH electrode and (c) NiAl LDO/LDS electrode at different
current densities. (d) Specific capacitances of NiAl LDH and NiAl LDO/LDS electrodes at
different current densities.

- 12
- 13



Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35.

Published on 21 August 2017. Downloaded by University of East Anglia Library on 31/08/2017 09:18:35

Journal of Materials Chemistry A

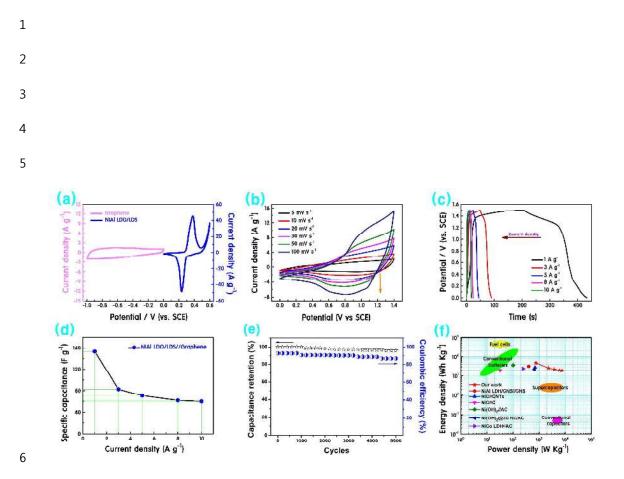


Fig. 8 Cyclic voltammograms of (a) graphene and NiAl LDO/LDS at a scan rate of 5 mV s⁻¹
and (b) NiAl LDO/LDS//G ASC device at different scan rate. (c) GCD curves of NiAl
LDO/LDS//G ASC device at different current densities, (d) Specific capacitances of NiAl
LDO/LDS//G ASC device at different current densities. (e) Cycling performance and
Coulombic efficiency of NiAl LDO/LDS//G ASC device at 5 A g⁻¹. (f) Ragone plot of NiAl
LDO/LDS//G ASC device

- 13
- 14
- 15